## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No
Filing Date July 13, 2001
Inventorship Cem Basceri et al.
Assignee Micron Technology, Inc.
Group Art Unit
Examiner Eric B. Fuller
Attorney's Docket No
Jitle: Ćhemical Vapor Deposition Methods of Forming Barium Strontium Titanate

Comprising Dielectric Layers, Including Such Layers Having a Varied Concentration of Barium and Strontium Within the Layer



## **RESPONSE TO MAY 20, 2002 FINAL OFFICE ACTION** PRELIMINARY AMENDMENT TO ACCOMPANY RCE FILING

To:

Box RCE

Assistant Commissioner for Patents

Washington, D.C. 20231

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From:

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Please enter the following amendments prior to examining the aboveidentified application.

## **AMENDMENTS**

## In the Claims

Please replace the claims with the following clean version of the entire set of pending claims. Cancel all previous versions of any pending claim. As there are no amendments to the claims, and one addition to same, no marked-up version of the claims is provided herewith in any accompanying pages separate from this amendment.